

Number	Hits	Search Text	IP	Date/Time
3	4	((brush or scrub) with (planariz\$3 or leveling) with (insulating or film or layer) and ((clean or cleaning) or contaminant))	USPAT; US-PGPUB	2003/01/29 12:40
4	12	((brush\$3 or scrub\$3) with (planariz\$3 or leveling)) and ((clean or cleaning) and contaminant and wafer)	USPAT; US-PGPUB	2003/01/29 12:50
5	11	SPONGE POLISHING	USPAT	2003/01/29 13:00
6	89	PVA and ((scrub or scrubbing or scrubed) same (surface or wafer) same (polishing or polished or polish)) and semiconductor	USPAT; US-PGPUB	2003/01/29 13:04
7	429	pva with (sponge or roller or brush)	USPAT; US-PGPUB	2003/01/29 13:06
8	181	mechanical with sponge	USPAT; US-PGPUB	2003/01/29 13:07
9	1069	mechanical with scrub or scrubbing	USPAT; US-PGPUB	2003/01/29 13:07
10	46	mechanical with (scrub or scrubbing) and (pva with (sponge or roller or brush))	USPAT; US-PGPUB	2003/01/29 13:08
21	1	"10/07-254"	USPAT;	2003/01/29 15:24
22	25	(bake or baking) with resin with vacuum	USPAT; US-PGPUB	2003/01/29 15:40
23	1	(bake or baking) with resin with vacuum and semiconductor	USPAT; US-PGPUB	2003/01/29 15:41
24	149	((bake or baking) with vacuum) SAME (polyimide or resist or polyamide or acryli or ECB or benzocyclobutene)	USPAT; US-PGPUB	2003/01/29 15:53
25	93	((bake or baking) with vacuum) SAME (polyimide or resist or polyamide or acryli or ECB or benzocyclobutene) and semiconductor	USPAT; US-PGPUB	2003/01/29 15:41
31	8	((bake or baking) with vacuum) SAME (polyimide or resist or polyamide or acryli or ECB or benzocyclobutene) and semiconductor) and moisture	USPAT; US-PGPUB	2003/01/29 16:10
32	147	((bake or baking) with vacuum) SAME (polyimide or photoresist or resist or polyamide or acryli or ECB or benzocyclobutene or resin) SAME moisture	USPAT; US-PGPUB	2003/01/29 16:10
33	27	((bake or baking) with vacuum) SAME (polyimide or photoresist or resist or polyamide or acryli or ECB or benzocyclobutene or resin) SAME moisture and semiconductor	USPAT; US-PGPUB	2003/01/29 16:10
34	25665	"polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkyamine" or "polyoxyethylene alkyamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether"	USPAT; US-PGPUB	2003/01/29 16:10
35	6063	"polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkyamine" or "polyoxyethylene alkyamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether" and antistatic or "anti static" or electrostatic contamination or "antistatic"	USPAT; US-PGPUB	2003/01/29 16:10

48	450	((("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") and (antistatic or "anti static" or electrostatic or contamination or semiconductors)) and (IC or ICI or "light emitting")	USPAT; US-PGPUB	2003/01/29 16:13
50	173	((conductive ADJ2 (polymer or organic)) with (electrostatic or "electro static" or "anti static"))	USPAT; US-PGPUB	2003/01/29 16:39
58	2	((("6,063,635" or ("6,064,040"))).PN.	USPAT; US-PGPUB	2003/01/29 16:17
46	16	((conductive ADJ2 (polymer or organic)) with (electrostatic or "electro static" or "anti static")) and ("polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") and semiconductor	USPAT; US-PGPUB	2003/01/29 17:46
54	932	((("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants))	USPAT; US-PGPUB	2003/01/29 17:15
52	100	((("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants)) and (semiconductor or IC or "integrated circuit")	USPAT; US-PGPUB	2003/01/29 17:15

144 "polyethylene glycol" or "polyethylene glycol ether" or "polyaniline" or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants)) and (semiconductor or IC or "integrated circuit")) not ((conductive AFM (polymer or organic)) with (electrostatic or "electro static" or "anti static")) and ("polyethylene glycol" or "polyaniline" or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") and semiconductor

145 "polyethylene glycol" or "polyethylene glycol ether" or "polyaniline" or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants)) and (semiconductor or IC or "integrated circuit")) not ((conductive AFM (polymer or organic)) with (electrostatic or "electro static" or "anti static")) and ("polyethylene glycol" or "polyaniline" or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") and semiconductor

783 ((("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants)) and ((("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") same (antistatic or "anti static" or electrostatic or contamination or contaminants)) and (semiconductor or IC or "integrated circuit") not ((conductive ADJ2 (polymer or organic); with electrostatic or "electro static" or "anti static" and ("polyethylene dioxythiophene" or polyaniline or "glycerin fatty acid ester" or "polyoxyethylene alkyl ether" or "alkyl diethanolamide" or "polyoxyethylene alkylamine" or "polyoxyethylene alkylamine fatty acid ester" or "alkyl sulfonate" or "alkylbenzenesulfonate" or "alkyl phosphate" or "tetraalkylammonium salt" or "trialkylbenzylammonium salt" or "alkyl betaine" or "alkyl imidazolium betaine" or "polyoxyethylene alkylphenyl ether") and semiconductor))

USPAT;
US-PGFEUB

2003/01/29 17:11

0	"0993235").PN.	EPO	2003/01/29 18:43
0	"0993235"	EPO	2003/01/29 18:44
28	yodasaka	EPO	2003/01/29 18:44
1	"20020066902").PN.	USPAT;	2003/01/29 18:45
		US-PGPUB	
1	"20020058304").PN.	USPAT;	2003/01/29 18:46
		US-PGPUB	
1	"6461748").PN.	USPAT;	2003/01/27 18:46
		US-PGPUB	
229	TFT SAME (EL or "electro luminescent" or electroluminescent)	USPAT;	2003/01/27 18:46
		US-PGPUB	
322	TFT SAME (EL or "electro luminescent" or electroluminescent) and (heat\$3 or treatment\$3 or anneal\$3 or annealing\$3 and plasma	USPAT;	2003/01/27 18:49
		US-PGPUB	
343	TFT and ((drain or source) with electrode) SAME (anode or cathode)	USPAT;	2003/01/27 18:49
		US-PGPUB	
42	("3807037" "3885196" "3910090" "4006383" "4042854" "4356429" "4409724" "4523189" "4539507" "4602192" "4720432" "4950950" "5047360" "5047687" "5059861" "5061569" "5073446" "5150006" "5151008" "5235193" "5235193" "5294870").PN.	USPAT	2003/01/27 18:49
58	5550066).EPEN.	USPAT	2003/01/27 18:49
12	TFT and ((insulating or passivating or passivation) with anode) same (heat\$3 or anneal\$3 or plasma)	USPAT;	2003/01/27 18:49
		US-PGPUB	
67	TFT and ((insulating or passivating or passivation) SAME anode same (heat\$3 or anneal\$3 or plasma))	USPAT;	2003/01/27 18:49
		US-PGPUB	
39	(TFT and ((insulating or passivating or passivation) SAME anode same (heat\$3 or anneal\$3 or plasma))) not (TFT and ((insulating or passivating or passivation) with anode) same (heat\$3 or anneal\$3 or plasma))	USPAT;	2003/01/27 18:49
		US-PGPUB	
219	((resin or insulating or dielectric) with (cured or curing)) and TFT	USPAT;	2003/01/27 18:49
		US-PGPUB	
117	((resin or insulating or dielectric) with (cured or curing)) and TFT) and (plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride"))	USPAT;	2003/01/27 18:49
		US-PGPUB	
68	((resin or insulating or dielectric) with (cured or curing)) and TFT) and (plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or EL or electroluminescent)	USPAT;	2003/01/27 18:49
		US-PGPUB	
253	OLED and TFT	USPAT;	2003/01/27 18:49
		US-PGPUB	
90	OLED and TFT) and (plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride"))	USPAT;	2003/01/27 18:49
		US-PGPUB	
20423	(plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride"))	USPAT;	2003/01/27 18:49
		US-PGPUB	
1715	(plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) and tft	USPAT;	2003/01/27 18:49
		US-PGPUB	
2044	(plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or "light emitting" or LED)	USPAT;	2003/01/27 18:49
		US-PGPUB	
492	((plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or "light emitting" or LED)) and tft	USPAT;	2003/01/27 18:49
		US-PGPUB	

-	135	((plasma SAME (hydrogen or nitrogen or halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or "light emitting" or LED); and tft) not yamazaki	USPAT; US-PGPUB	2003/01/27 12:54
-	214	((plasma SAME (hydrogen or nitrogen or halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or "light emitting" or LED); and tft) not yamazaki) not (((((resin or insulating or dielectric with (cured or curing or cure) and TFT) and plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) and (luminescen\$2 or EL or electroluminescen\$2)))	USPAT; US-PGPUB	2003/01/27 12:54
-	214	((plasma SAME (hydrogen or nitrogen or halogenated ADJ1 carbon) or "hydrogen fluoride")) same (insulating or resin,	USPAT; US-PGPUB	2003/01/27 12:54
-	484	((plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) same (insulating or resin) and moisture)	USPAT; US-PGPUB	2003/01/27 12:54
-	727	((plasma) with (treatment or treating) and TFT	USPAT; US-PGPUB	2003/01/27 12:54
-	111	plasma with (treatment or treating) and (luminescen\$2 or EL or electroluminescen\$2 or "light emitting")	USPAT; US-PGPUB	2003/01/27 12:54
-	111	plasma SAME (hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride")) same (insulating or resin) and moisture) not yamazaki	USPAT; US-PGPUB	2003/01/27 12:54
-	111	resin with (cured or curing or cure) with plasma	USPAT; US-PGPUB	2003/01/27 12:54
-	78	(hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and (resin with (cured or curing or cure) with plasma)	USPAT; US-PGPUB	2003/01/27 12:54
-	111	(hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride" and (resin with (cured or curing or cure) with plasma)) and (tft or EL "luminescent")	USPAT; US-PGPUB	2003/01/27 12:54
-	1031	(insulating with resin) and (insulating same plasma)	USPAT; US-PGPUB	2003/01/27 12:54
-	967	(hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and ((insulating with resin) and (insulating same plasma)	USPAT; US-PGPUB	2003/01/27 12:54
-	111	insulating same resin same plasma	USPAT; US-PGPUB	2003/01/27 12:54
-	1031	insulating with resin with surface with treatment	USPAT; US-PGPUB	2003/01/27 12:54
-	919	(hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and (insulating same resin same plasma)	USPAT; US-PGPUB	2003/01/27 12:54
-	1031	insulating with resin with surface with treatment) not ((hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and (insulating same resin same plasma))	USPAT; US-PGPUB	2003/01/27 12:54
-	919	((insulating with resin with surface with treatment, not ((hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and (insulating same resin same plasma)) and plasma	USPAT; US-PGPUB	2003/01/27 12:54
-	111	insulating with resin with surface with treat\$4	USPAT; US-PGPUB	2003/01/27 12:54
-	105	(insulating with resin with surface with treat\$4) not ((hydrogen or nitrogen or (halogenated ADJ1 carbon) or "hydrogen fluoride") and (insulating same resin same plasma))	USPAT; US-PGPUB	2003/01/27 12:54

[illegible]

"4720482"-LEN.

USEAT;
US-PCHE

2003/01/28 16:16

Line Number	Hits	Search Text	IP	Time Stamp
-	1	448376.PRN.	USPAT; US-PGPUB	2003/01/17 14:17
-	2	4481334.URN.	USPAT	2003/01/17 14:17
-	3	("4266334" ; "4294911" ; "4308368").PN.	USPAT	2003/01/17 14:17
-	2	("4753819" ; "5108754").PN.	USPAT	2003/01/17 14:17
-	3	5707666.URN.	USPAT	2003/01/17 14:17
-	11048	((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor))	USPAT; US-PGPUB	2003/01/17 14:17
-	480	((temporary or temporarily or remov\$3 with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor)) and dust	USPAT;	2003/01/17 14:17
-	53	((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) ; same dust)and ("integrated circuit" or IC or semiconductor))	USPAT; US-PGPUB	2003/01/17 14:17
-	42	((temporary or temporarily or remov\$3, with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor)) and dust) not (((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) ; same dust)and ("integrated circuit" or IC or semiconductor))	USPAT; US-PGPUB	2003/01/17 14:17
-	149	((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor)) and ("clean room")	USPAT; US-PGPUB	2003/01/17 14:17
-	115	((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor) and ("clean room") not (((temporary or temporarily or remov\$3 with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor)) and dust) not (((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) ; same dust)and ("integrated circuit" or IC or semiconductor)))	USPAT; US-PGPUB	2003/01/17 14:17
-	116	((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor) and ("clean room") not (((temporary or temporarily or remov\$3; with (protect\$3 or covering) with (film or layer) and ("integrated circuit" or IC or semiconductor)) and dust) not (((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) ; same dust)and ("integrated circuit" or IC or semiconductor)))) not (((temporary or temporarily or remov\$3) with (protect\$3 or covering) with (film or layer) ; same dust)and ("integrated circuit" or IC or semiconductor));	USPAT; US-PGPUB	2003/01/17 14:17
11	11	"4151544" ; "4388034" ; "4499416" ; "4592396" ; "4642243" ; "4670126" ; "4824545" ; "5024570" ; "5240152" ; "5271136" ; "5310410"/.PN.	USPAT	2003/01/17 14:17

Number	Hits	Search Text	EB	Time stamp
1037	1	("electro luminescent" or "light emitting") or TFT	USPAT; US-PGPUB	2002/09/19 11:21
1038	1	("electro luminescent" or "light emitting") or TFT; and anode and cathode	USPAT; US-PGPUB	2002/09/19 11:21
1039	1	("electro luminescent" or "light emitting") or TFT) and anode and cathode) and (PVA or "polyvinyl")	USPAT; US-PGPUB	2002/09/20 15:51
1040	1	("electro luminescent" or "light emitting") or TFT) and ((PVA or "polyvinyl") WITH anode)	USPAT; US-PGPUB	2002/09/20 15:51
1041	1	anode WITH (clean or cleaning or wiping or cleaned), SAME (PVA or polyvinyl or "poly(vinyl)")	USPAT; US-PGPUB	2002/09/19 16:34
1042	1	PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol)	USPAT; US-PGPUB	2002/09/19 16:34
1043	1	(PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol) SAME (ITO or "tin oxide" or "SNO.sub.2" or "indium oxide" or "zinc oxide" or ZnO or gold or polyaniline or anode)	USPAT; US-PGPUB	2002/09/19 16:34
1044	1	(PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol) SAME (ITO or "tin oxide" or "SNO.sub.2" or "indium oxide" or "zinc oxide" or ZnO or gold or polyaniline or anode) and (clean or cleaning or dust or wiping or wipe)	USPAT; US-PGPUB	2002/09/20 18:16
1045	1	(PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol) SAME (ITO or "tin oxide" or "SNO.sub.2" or "indium oxide" or "zinc oxide" or ZnO or gold or polyaniline or anode) and (clean or cleaning or dust or wiping or wipe) and TFT or light or electroluminescent)	USPAT; US-PGPUB	2002/09/20 18:16
1046	1	(PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol) WITH (clean or cleaning)	USPAT; US-PGPUB	2002/09/20 18:16
1047	1	("Re26893" or "2998241" or "4126647" or "4351962" or "4741918" or "5156780").PN.	USPAT	2002/09/20 11:31
1048	1	5693742.URPN.	USPAT	2002/09/20 18:03
1049	1	(PVA or ((polyvinyl or "poly(vinyl)") ADJ2 alcohol) WITH (clean or cleaning) WITH PVA)	USPAT; US-PGPUB	2002/09/20 15:16
1050	1	("3,260,612").PN.	USPAT; US-PGPUB	2002/09/20 15:16
1051	1	("electro luminescent" or "light emitting") or TFT) and (anode and cathode) and (clean or cleaning)	USPAT; US-PGPUB	2002/09/20 18:16
1052	1	("electro luminescent" or "light emitting") or TFT) and ((anode and cathode) SAME (clean or cleaning))	USPAT; US-PGPUB	2002/09/20 18:16
1053	1	("electro luminescent" or "light emitting") or TFT) and ((anode and cathode) SAME (clean or cleaning))) and (438/\$.cols. or 257/\$.cols.)	USPAT; US-PGPUB	2002/09/20 18:16
1054	1	("electro luminescent" or "light emitting") or TFT) and (ITO and (clean or cleaning))	USPAT; US-PGPUB	2002/09/20 18:16
1055	1	((("electro luminescent" or "light emitting") or TFT) and (ITO and (clean or cleaning) and (438/\$.cols. or 257/\$.cols.	USPAT; US-PGPUB	2002/09/20 18:16
1056	1	(semiconductor or "integrated circuit" and (clean or cleaning) with room)	USPAT; US-PGPUB	2002/09/20 18:16
1057	1	((semiconductor or "integrated circuit") and (clean or cleaning) with room) and (contaminant or dust)	USPAT; US-PGPUB	2002/09/20 18:16
1058	1	((semiconductor or "integrated circuit") and (clean or cleaning) with room) and (contaminant or dust.) and (electrostatic or "anti electrostatic".	USPAT; US-PGPUB	2002/09/20 18:16

41	semiconductor or "integrated circuit", and ((clean or cleaning) with room)) and (contaminant or dust)) and (electrostatic or "anti electrostatic") and polyimide	USPAT; US-PGPUB	2002/09/20 18:29
1322	protective or protection or contamination or contaminants or protects or protect	USPAT; US-PGPUB	2002/09/20 18:29
1322	protective or protection or contamination or contaminants or protects or protect) with (transport or transporting or transported or move or moving or moved)	USPAT; US-PGPUB	2002/09/20 18:29
1322	protective or protection or contamination or contaminants or protects or protect) with (transport or transporting or transported)	USPAT; US-PGPUB	2002/09/20 18:29
1322	polyimide and (protective or protection or contamination or contaminants or protects or protect) and (transport or transporting or transported) and (semiconductor or "integrated circuit" or VLSI)) and ((protective or protection or contamination or contaminants or protects or protect) with (transport or transporting or transported))	USPAT; US-PGPUB	2002/09/20 18:29
1322	semiconductor or "integrated circuit" and ((clean or cleaning) with room)) and (contaminant or dust)) and ((clean or cleaning) or (rooms or chambers))	USPAT; US-PGPUB	2002/09/20 18:29
1322	oxide or ITO with insulating with organic	USPAT; US-PGPUB	2002/09/20 18:29
1322	"5,294,969".PN.	USPAT; US-PGPUB	2002/09/20 18:29
1322	438/69).CCLS.	USPAT; US-PGPUB	2002/09/20 18:29
1322	"organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent"	USPAT; US-PGPUB	2002/09/20 18:29
1322	"organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent") and (anode and cathode)	USPAT; US-PGPUB	2002/09/20 18:29
1322	("organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent") and (anode and cathode) and (insulating with anode)	USPAT; US-PGPUB	2002/09/20 18:29
1322	((("organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent", and (anode and cathode) and (insulating with anode)) and (clean or cleaning)	USPAT; US-PGPUB	2002/09/20 18:29
1322	"organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent") and (anode and cathode) and (room or chamber)	USPAT; US-PGPUB	2002/09/20 18:29
1322	("organic EL" or "organic electroluminescent" or "organic luminescence" or "organic luminescent" and (anode and cathode)) and (room or chamber) SAME (protective or contaminant))	USPAT; US-PGPUB	2002/09/20 18:29
1322	"anti electrostatic" with (layer or film)	USPAT; US-PGPUB	2002/09/20 18:29
1322	"4892947" ; "4892753" ; "4895291" ; "5817431" ; "5963626" ; "6031413" ; "6031413" ; "6031413".PN.	USPAT; US-PGPUB	2002/09/20 18:29
1322	"anti electrostatic" with (layer or film) and room	USPAT; US-PGPUB	2002/09/20 18:29
1322	(pixel with (laminate)) SAME (room or clean or contaminant or dust)	USPAT; US-PGPUB	2002/09/20 18:29

-	12	anode with (laminate); SAME (room or clean or contaminant or dust)	USPAT;	2012/07/01 14:17
-	13	(passivation or polyimide or protective with temporary or sacrificial); SAME (remove or removing or removed) SAME (transport or transported or transporting)	USPAT; US-PGPUB	2012/07/01 14:17
-	36	(passivation or polyimide or protective with (temporary or sacrificial); SAME (remove or removing or removed)	USPAT; US-PGPUB	2012/07/01 14:17
-	44	(passivation or polyimide or protective with (temporary or sacrificial)) SAME (remove or removing or removed)) and (contaminant) and (semiconductor or "integrated circuit" or visi)	USPAT; US-PGPUB	2012/07/01 14:17
-	16	(passivation or polyimide or protective) with (temporary or sacrificial); SAME (remove or removing or removed)) and (contaminant) and (semiconductor or "integrated circuit" or visi); and (light or EL)	USPAT; US-PGPUB	2012/07/01 14:17